

ABSTRACT

It is an object of the present invention to provide a cleaning treatment material that exhibits cleaning capacity superior to that of a conventional photosemiconductor catalyst in a case wherein the weight of the cleaning treatment material that can support an air cleaning member is limited to a certain extent. The cleaning treatment material (847) is a mixture of a photosemiconductor catalyst (846) and an apatite (845), which has a photocatalytic function. Furthermore, the secondary particles of the photosemiconductor catalyst (846) are 0.1 to 1.0 μm in diameter. In addition, the secondary particles of the apatite (845) are 1 to 10 μm in diameter.